





A15 materials thin films and HiPIMS progress at CERN for SRF cavities

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CERN



Outline

HiPIMS

- Principle
- Setup
- Latest results
- Next steps

• A15

- Goal
- Setup
- Results
- Next steps
- Conclusion



HiPIMS coatings progress



Principle

High Power Impulse Magnetron Sputtering

- Pulsed power supply (~100µs pulses, 1% duty cycle up to 1kHz)
- Power density
 - DC: 12 W.cm⁻²
 - HiPIMS: ~1kW.cm⁻²
- Ionization of sputtered species up to 90%
- Better coating conformity
- Lower substrate heat-up
- Lower coating rate : ions captured at the cathode
- Very sensitive to cathode surface state (roughness) → arcing





Motivation

Systematic Q-slope degradation when lowering cavity beta value



Motivation

• Encouraging first coating (G. Terenziani)

- H6.8: Highest-field magnetron cavity (EP+SUBU)
- H8.4: Best-ever magnetron cavity (full EP)
- M2.3: Latest HIPIMS cavity (EP+SUBU)



HiPIMS performs close to the best ever achieved magnetron coated cavities.

How to go farther?



4/4/2016

CERN Setup



Kr process gas Differential pumping RGA (process quality control and leak detection) Bakeout system (base pressure ~ 5.10⁻¹⁰ mbar) Controlled venting: Dry Air



HiPIMS Power supply + capacitors bank



Bias power supply

CERN Setup





All scale bars are $400 \mu m$

- No major improvement from grounded to biased DCMS
- Grounded HiPIMS equivalent to DCMS
- Biased HiPIMS shows densification of the layer no matter the orientation



4/4/2016

Document reference

Next steps

• M2.10 (1.3 GHz) coated with HiPIMS/-100V bias. RF characterization pending.



- Samples FIB preparation and analysis on going : Substrate/Nb layer interface, porosity evaluation...
- Pursue HiPIMS coatings to validate/exclude technological approach by end 2016.
- Propose new magnetic configurations to enhance Nb ions flux at the substrate.
- QPR to investigate the superconductive RF properties.
- Exploration of SC DC properties (magnetometer, T_C...)



A15 Materials



Goal

- Propose an alternative to Nb films for SRF accelerating cavities
- Candidates should have:





Coating Setup

Planar DC magnetron sputtering







150mm Nb/Sn and V/Si targets at 3:1 at. Ratio.
Ar sputtering gas
200W sputtering power
1.10⁻³ mbar up to 5.10⁻² mbar working pressure

Alloyed target \rightarrow possible scale-up to cavity size coatings



3rd July 2015

Results

Nb₃Sn Room temperature coatings + annealing



As deposited layer: nanocrystal but mainly amorphous

After annealing: A15 phase obtained even after annealing at low temperature.

DC measures confirm the obtention of a superconducting phase Strong hysteresis suggests flux pinning



Next steps

- EUCARD-2 deliverable D12.5: Postponed to Aug 2016 because of QPR system repair.
- Understand the effect of surface preparation (surface energy measurements, roughness ...)
- Recommissioning of the T_c measurement setup (induction)
- First promising results from high temperature coatings : to be investigated in depth.
- V_3 Si coatings already started:
 - Stoichiometry issue : process gas?
 - XRD on going
- DC properties interpretation





Communications

2015

Poster at HiPIMS 2015, Braunschweig: BIASED HiPIMS TECHNOLOGY FOR SUPERCONDUCTING RF ACCELERATING CAVITIES COATING

DEVELOPMENT OF Nb3Sn COATINGS BY MAGNETRON SPUTTERING FOR SRF CAVITIES, G. Rosaz et al, SRF 2015 proceedings + POSTER

2016

Poster at FCC week, Rome : SUPERCONDUCTING SPUTTERED NB₃SN FILMS FOR SRF APPLICATIONS



CONCLUSION

- HiPIMS
 - Demonstrated very promising film morphology
 - First biased cavity coated RF measures on-going
 - Study RF performances vs parameters (pulse duration, peak power, frequency...)
 - Plasma characterization
- A15
 - Nb3Sn
 - A15 phase obtained after annealing. Superconductivity confirmed
 - High temperature coatings promising
 - V3Si
 - First coatings done and under characterization
 - QPR coating by end Aug 2016
 - T_c measurement bench to be requalified

